

GaAs MMIC SUB-HARMONICALLY PUMPED MIXER 33 - 42 GHz

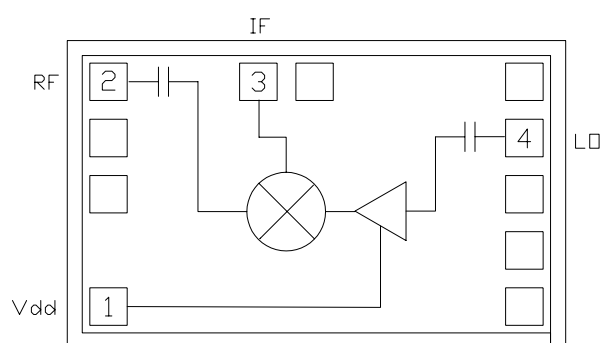
Typical Applications

33 and 42 GHz Microwave Radios

Up and Down Converter for
Point to Point Radios

Satellite Communication Systems

Functional Diagram



Features

Integrated LO Amplifier: +2 dBm Input

Sub-Harmonically Pumped (x2) LO

High 2LO/RF Isolation: > 37 dB

Small Size: 0.81mm x 1.32mm

General Description

The HMC339 chip is a sub-harmonically pumped (x2) MMIC mixer with an integrated LO amplifier which can be used as an upconverter or downconverter. The chip utilizes a GaAs PHEMT technology that results in a small overall chip area of 1.07mm². The 2LO to RF isolation is excellent eliminating the need for additional filtering. The LO amplifier is a single bias (+3V to +4V) two stage design with only +2 dBm nominal drive requirement. All data is measured with the chip in a 50 ohm test fixture connected via 0.025mm (3 mil) ribbon bonds of minimal length <0.31 mm (<12 mils).

Guaranteed Performance, As a Function of Vdd, 25 Deg °C

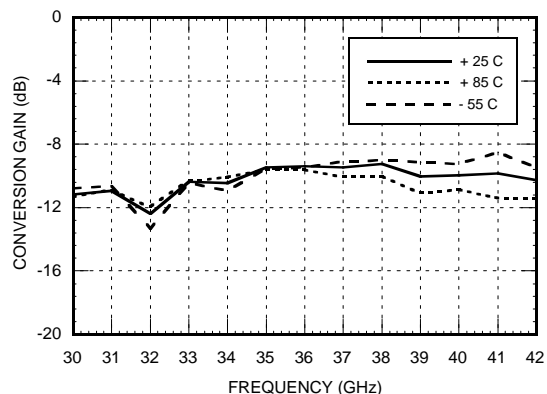
Parameter	IF= 1 GHz LO= +2 dBm & Vdd= +4V			IF= 1 GHz LO= +2 dBm & Vdd= +3V			Units
	Min.	Typ.	Max.	Min.	Typ.	Max.	
Frequency Range, RF		33 - 42			33 - 38		GHz
Frequency Range LO		16.5 - 21			16.5 - 19		GHz
Frequency Range, IF		DC - 3			DC - 3		GHz
Conversion Loss		10	13		10	12	dB
Noise Figure (SSB)		10	13		10	12	dB
2LO to RF Isolation	27	37		23	37		dB
2LO to IF Isolation	30	40		25	40		dB
IP3 (Input)	5	10		3	8		dBm
1 dB Compression (Input)	-4	0		-5	-1		dBm
Supply Voltage (Vdd)		4.0			3.0		Vdc
Supply Current (Idd)		28			25		mA

**Unless otherwise noted, all measurements performed as downconverter, IF= 1 GHz.*

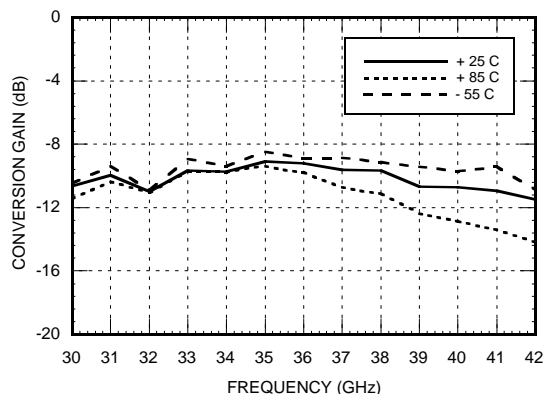
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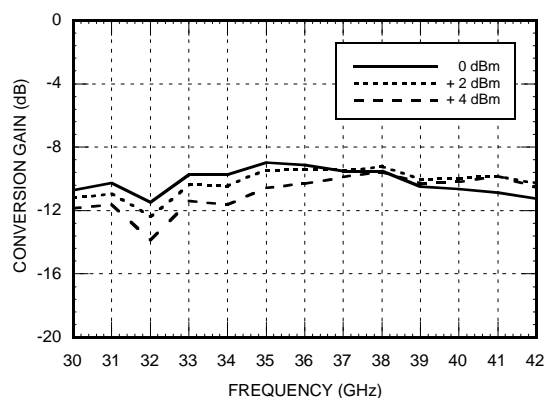
Conversion Gain vs. Temperature @ LO = +2 dBm, Vdd = +4V



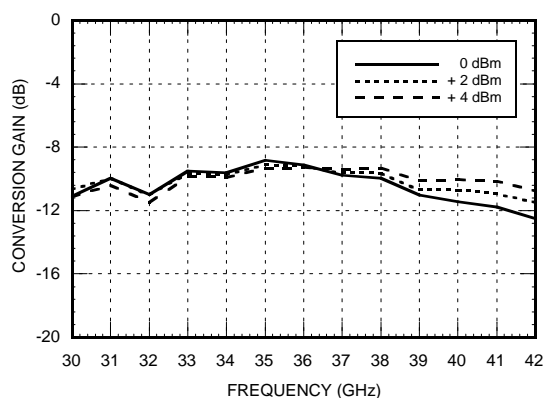
Conversion Gain vs. Temperature @ LO = +2 dBm, Vdd = +3V



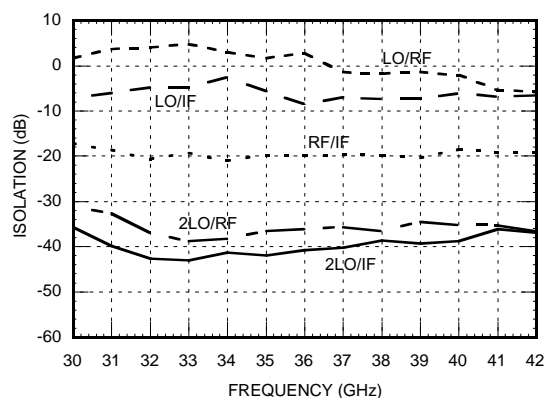
Conversion Gain vs. LO Drive @ Vdd = +4V



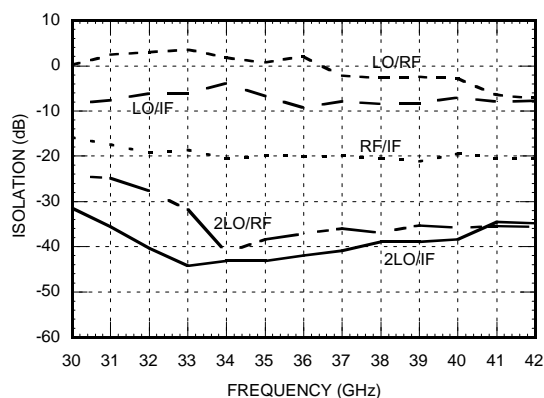
Conversion Gain vs. LO Drive @ Vdd = +3V



Isolation @ LO = +2 dBm, Vdd = +4V

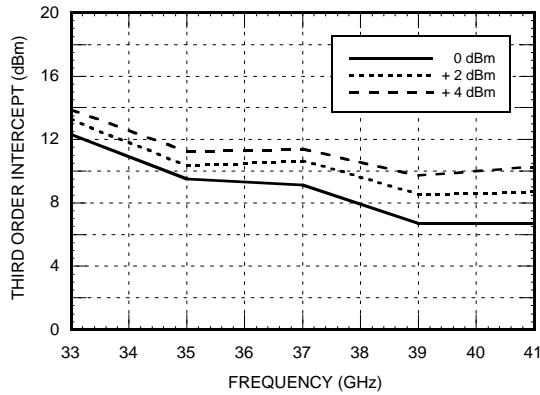


Isolation @ LO = +2 dBm, Vdd = +3V

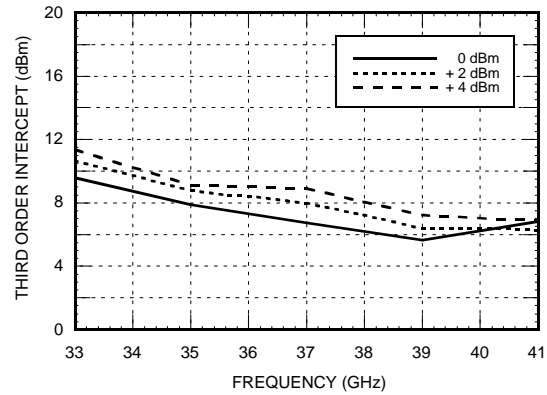


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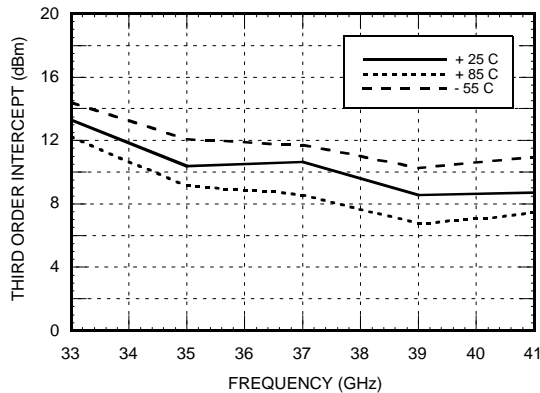
Input IP3 vs. LO Drive @ Vdd = +4V*



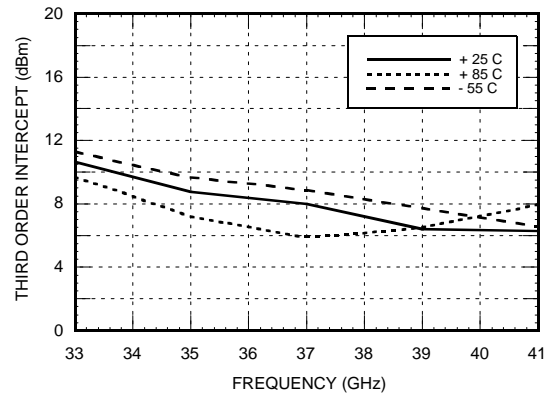
Input IP3 vs. LO Drive @ Vdd = +3V*



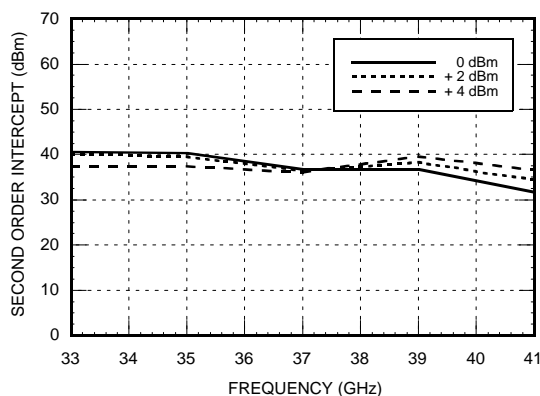
**Input IP3 vs. Temperature
@ LO = +2 dBm, Vdd = +4V***



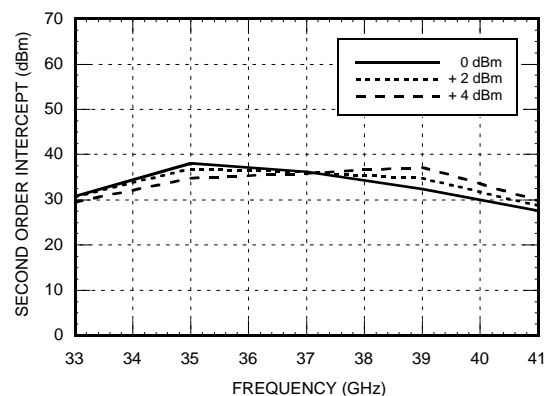
**Input IP3 vs. Temperature
@ LO = +2 dBm, Vdd = +3V***



Input IP2 vs. LO Drive @ Vdd = +4V*



Input IP2 vs. LO Drive @ Vdd = +3V*

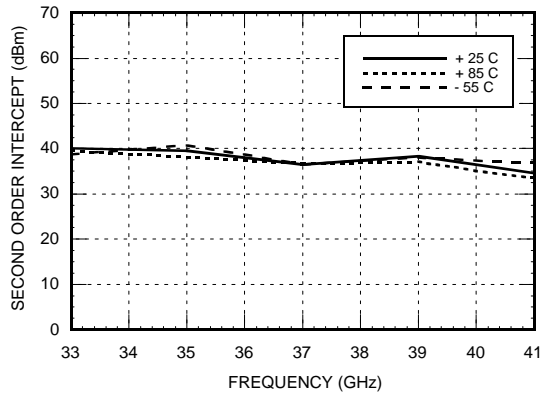


* Two-tone input power = -10 dBm each tone, 1 MHz spacing.

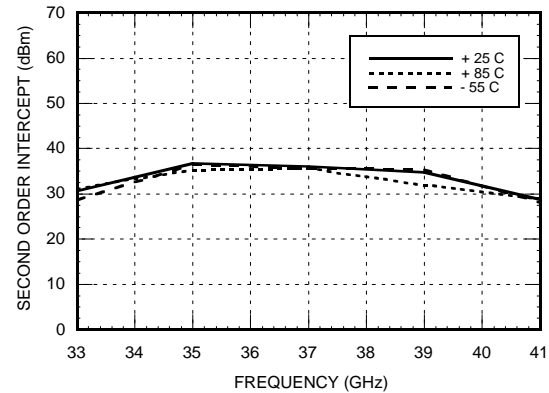
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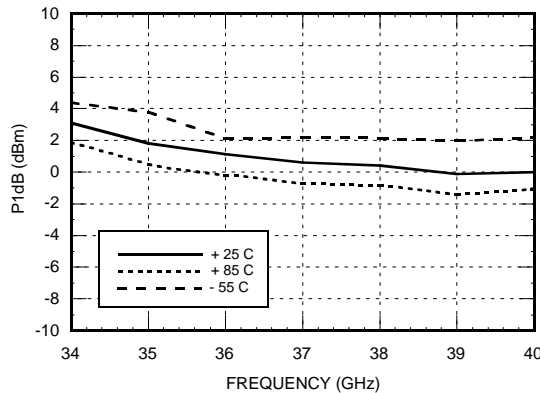
Input IP2 vs. Temperature
@ LO = +2 dBm, Vdd = +4V*



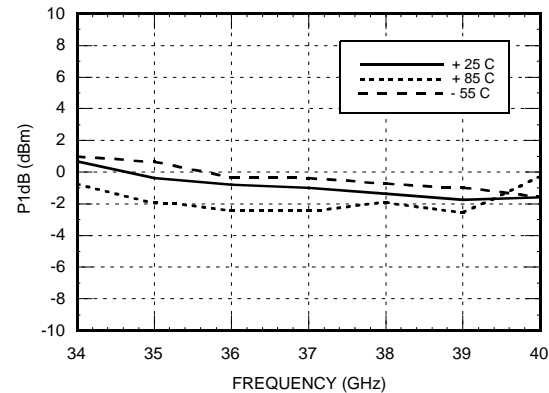
Input IP2 vs. Temperature
@ LO = +2 dBm, Vdd = +3V*



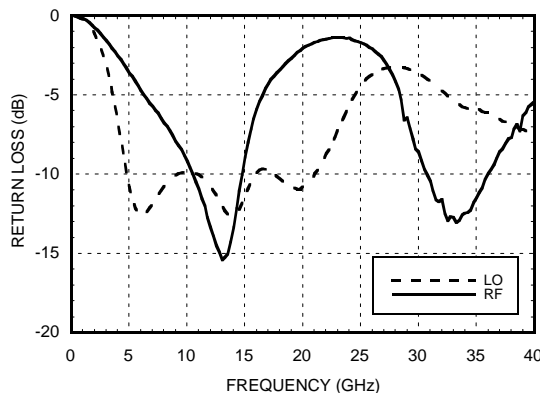
Input P1dB vs. Temperature
@ LO = +2 dBm, Vdd = +4V



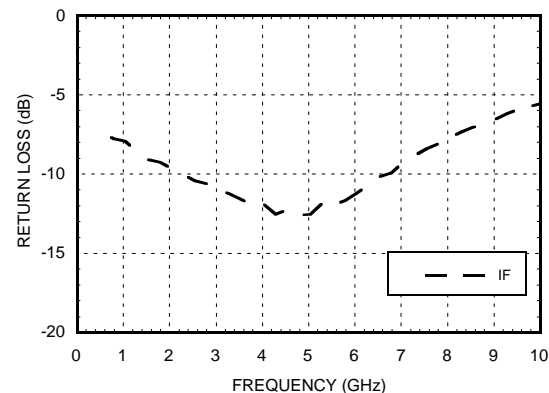
Input P1dB vs. Temperature
@ LO = +2 dBm, Vdd = +3V



RF & LO Return Loss
@ LO = +2 dBm, Vdd = +4V



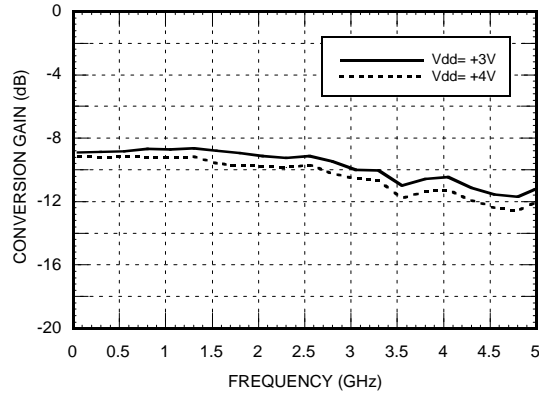
IF Return Loss
@ LO = +2 dBm, Vdd = +4V



* Two-tone input power = -10 dBm each tone, 1 MHz spacing.

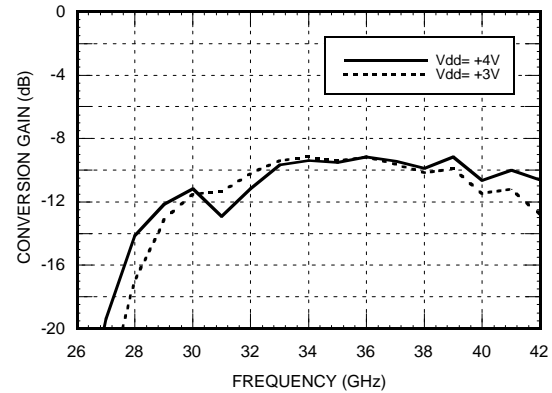
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IF Bandwidth @ LO = +2 dBm



Upconverter Performance

Conversion Gain, LO = +2 dBm, Vdd = +4V



Absolute Maximum Ratings

RF / IF Input (Vdd = +5V)	+13 dBm
LO Drive (Vdd = +5V)	+13 dBm
Vdd	+5.5V
Continuous Pdiss (Ta= 85 °C) (derate 2.64 mW/°C above 85 °C)	238 mW
Storage Temperature	-65 to +150 deg C
Operating Temperature	-55 to +85 deg C

MXN Spurious @ IF Port Outputs @ LO = +2 dBm, Vdd = +4V

	nLO					
mRF	± 5	± 4	± 3	± 2	± 1	0
-2	44					
-1		42	53			
0				18	-14	
1				X	42	13
2		55	47			

RF = 39 GHz @ -10 dBm
LO = 19 GHz @ +2 dBm
All values in dBc below IF power level.
Measured as downconverter

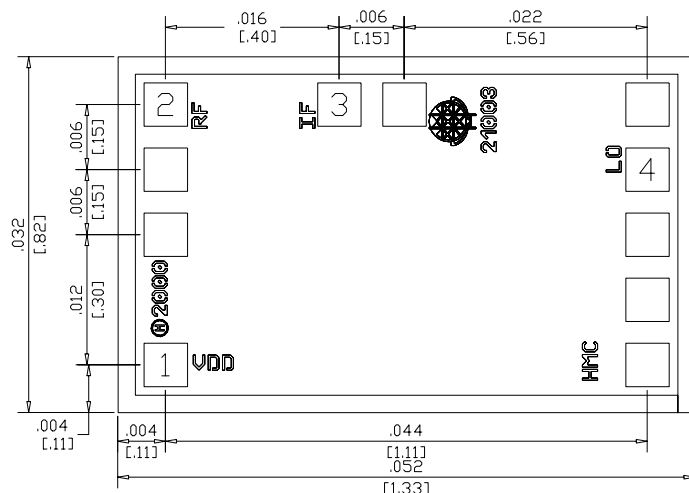
MXN Spurious @ RF Port Outputs @ LO = +2 dBm, Vdd = +3V

	nLO					
mIF	± 5	± 4	± 3	± 2	± 1	0
-2					30	
-1				X	36	
0				13	-20	
1				X	36	3
2					37	54

IF = 1 GHz @ -10 dBm
LO = 19 GHz @ +2 dBm
All values in dBc below RF power level.
Measured as upconverter


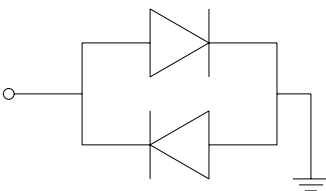

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Pad Locations & Outline Drawing



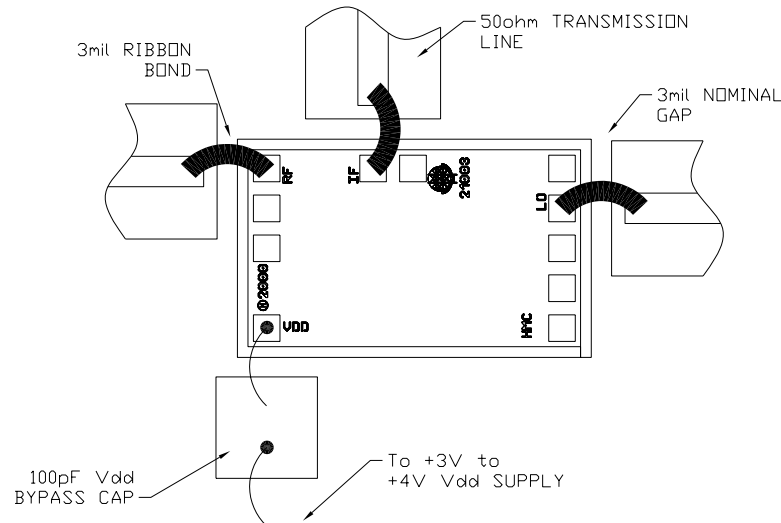
ALL DIMENSIONS IN INCHES (MILLIMETERS)
ALL TOLERANCES ARE ± 0.001 (0.025)
DIE THICKNESS IS 0.004 (0.100) BACKSIDE IS GROUND
BOND PADS ARE 0.004 (0.100) SQUARE
BOND PAD SPACING, CTR-CTR: 0.006 (0.150)
BACKSIDE METALLIZATION: GOLD
BOND PAD METALLIZATION: GOLD

Pad Description

Pad Number	Function	Description	Interface Schematic
1	Vdd	Power supply for the LO Amplifier. An external RF bypass capacitor of 100 - 330 pF is required. A MIM border capacitor is recommended. The bond length to the capacitor should be as short as possible. The ground side of the capacitor should be connected to the housing ground.	
2	RF Port	RF Port. This pad is AC coupled and matched to 50 ohm from 33 - 42 GHz.	
3	IF Port	IF Port. This pad is DC coupled and should be DC blocked externally using a series capacitor whose value has been chosen to pass the necessary IF frequency range. Any applied DC voltage to this pin will result in die non-function and possible die failure.	
4	LO Port	LO Port. This pad is AC coupled and matched to 50 ohm from 16 - 21 GHz	

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Assembly Diagrams



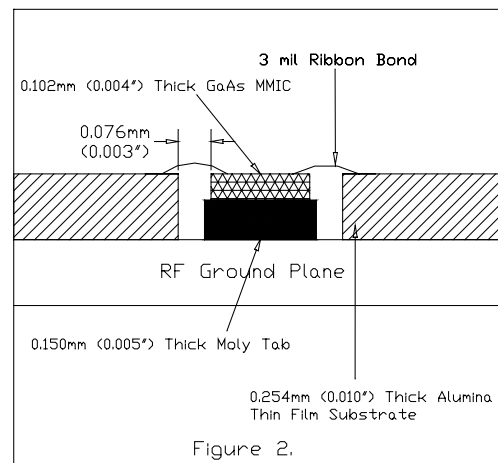
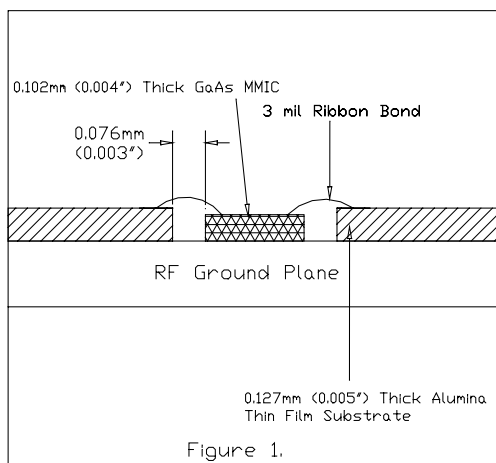
Mounting & Bonding Techniques for Millimeterwave GaAs MMICs

The die should be attached directly to the ground plane eutectically or with conductive epoxy (see HMC general Handling, Mounting, Bonding Note).

50 Ohm Microstrip transmission lines on 0.127mm (5 mil) thick alumina thin film substrates are recommended for bringing RF to and from the chip (Figure 1). If 0.254mm (10 mil) thick alumina thin film substrates must be used, the die should be raised 0.150mm (6 mils) so that the surface of the die is coplanar with the surface of the substrate. One way to accomplish this is to attach the 0.102mm (4 mil) thick die to a 0.150mm (6 mil) thick molybdenum heat spreader (moly-tab) which is then attached to the ground plane (Figure 2).

Microstrip substrates should be brought as close to the die as possible in order to minimize ribbon bond length. Typical die-to-substrate spacing is 0.076mm (3 mils). Gold ribbon of 0.075 mm (3 mil) width and minimal length <0.31 mm (<12 mils) is recommended to minimize inductance on RF, LO & IF ports.

An RF bypass capacitor should be used on the Vdd input. A 100 pF single layer capacitor (mounted eutectically or by conductive epoxy) placed no further than 0.762mm (30 Mils) from the chip is recommended.



**GaAs MMIC SUB-HARMONICALLY
PUMPED MIXER 33 - 42 GHz****Handling Precautions**

Follow these precautions to avoid permanent damage.

Cleanliness:

Handle the chips in a clean environment.
DO NOT attempt to clean the chip using liquid cleaning systems.

Static Sensitivity:

Follow ESD precautions to protect against > $\pm 250V$ ESD strikes (see page 8 - 2).

Transients:

Suppress instrument and bias supply transients while bias is applied.
Use shielded signal and bias cables to minimize inductive pick-up.

General Handling:

Handle the chip along the edges with a vacuum collet or with a sharp pair of bent tweezers.
The surface of the chip has fragile air bridges and should not be touched with vacuum collet, tweezers, or fingers.

Mounting

The chip is back-metallized and can be die mounted with AuSn eutectic preforms or with electrically conductive epoxy.
The mounting surface should be clean and flat.

Eutectic Die Attach:

A 80/20 gold tin preform is recommended with a work surface temperature of 255 deg. C and a tool temperature of 265 deg. C. When hot 90/10 nitrogen/hydrogen gas is applied, tool tip temperature should be 290 deg. C.
DO NOT expose the chip to a temperature greater than 320 deg. C for more than 20 seconds. No more than 3 seconds of scrubbing should be required for attachment.

Epoxy Die Attach:

Apply a minimum amount of epoxy to the mounting surface so that a thin epoxy fillet is observed around the perimeter of the chip once it is placed into position.
Cure epoxy per the manufacturer's schedule.

Wire Bonding

RF bonds made with 0.003" x 0.0005" ribbon are recommended. These bonds should be thermosonically bonded with a force of 40-60 grams. DC bonds of 0.001" (0.025 mm) diameter, thermosonically bonded, are recommended. Ball bonds should be made with a force of 40-50 grams and wedge bonds at 18-22 grams. All bonds should be made with a nominal stage temperature of 150 deg. C. A minimum amount of ultrasonic energy should be applied to achieve reliable bonds. All bonds should be as short as possible, less than 12 mils (0.31 mm).